U.S. Department of Commerce, Patent and Trademark Office						orney Dock	Serial No	Serial No.:			
O.O. Dopin diloni VI Commission, I man and a m						C0254US	Unassign	Unassigned			
INFORMATION DISCLOSURE STATEMENT BY APPLICANT						Applicant(s):					
(Use several sheets if necessary)						John W. Jacobs and Elizabeth A. Dauch					
						ing Date:	Group Ar	Group Art Unit:			
►EXPRESS MAIL LABEL NO.: EV 304 737 528 US◀						ncurrently h	Unassign	Unassigned			
				.S. Patent Documents		,					
*Examiner		Document				61	0.1-1	Filing Date			
Initial		Number	Date	Name Steinman et al.	\dashv	Class 361	Subclass 213		If Appropriate Dec. 29, 1988		
45	AA	4,901,194	Feb. 13, 1990				593				
LT	AB	6,077,762	Jun. 20, 2000	Victor C. Liang et al.				Dec. 22, 1997 Dec. 22, 1997			
4	AC	6,153,531	Nov. 28, 2000	Subhas Bothra, et al.		438	745	Dec. 22,	1997		
	AD										
	AE					/					
	AF										
	AG		/	1							
	AH		/								
	AI										
	AJ					/					
	AK		/			/					
	ـــــــ	·	Fo	reign Patent Documents	\mathcal{T}			-			
			/		/			Transl	ation		
	T T	Document /	Date	Country		Class	Subclass	Yes	No		
	AL										
	AM										
	AN										
	AO	1		1 /							
	AP			1 /							
		ОТН	ER ART (Includi	ng Author, Title, Date, P	ertin	ent Pages, E	tc.)				
	AQ	Rothra S H	Sur and V. Liang.	"A New Failure Mechan	nism	by Corrosion	n of Tungsten	in a Tungster	n Plug		
LT		Process," Tech	Bothra, S., H. Sur and V. Liang, "A New Failure Mechanism by Corrosion of Tungsten in a Tungsten Plug Process," Technology Development, VLSI Technology, Inc., San Jose, California, 95131; 1998 IEEE.								
	AR	 									
	AS	AS /									
					1						
Examiner:		Tuo	ulum			Date Co	onsidered:	6/28/0	,		
	ER. Ini			er or not citation is in con	form	ance with M					
citation if n	ot in co	nformance and no	ot considered. Inc	lude copy of this form w	/ith y	our commun	ication to app	licant.			

U.S. Department of Commerce, Patent and Trademark Office							orney Docl		Application No.:	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT						 	C0254US	<u> </u>	10/695,528	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)							olicant(s):		Confirmation No.:	
(Use several sheets if necessary) Jo						Joh	n W. Jacob	os .	6404	
<u>_i</u> .	anne &						ng Date:		Group Art Unit:	
(JUN 0 9 2005 E						Oct	ober 28, 20	003	2891	
·/	*Examines / RAPEN Document Document Initial Number Date									
*Exan	*Examiner / NA Initial		Document Number	Date	Name	Name		Subclass	Filing If Appre	
L		AA	5,336,371	Aug. 9, 1994	Chung et al.		Class 156	659.1	II What	Jpi iate
	l	AÐ	6,077,762	Jun. 20, 2000	Liang et al.		438	593	1.	
		AC	6,153,531	Nov. 28, 2000	Bothra et al.		438	745		
		AD	6,277,742 B1	Aug. 21, 2001			438	672		
		AE	6,284,055 B1	Sep. 4, 2001	Dryer et al.		134	10	 	
		AF	6,358,329 B1	Mar. 19, 2002	Muranaka et al.		134	26		
		AG	6,410,417 B1	Jun. 25, 2002	Tsai et al.		438	618		
L	T	AH	6,851,873 B2	Feb. 8, 2005	Muraoka et al.		396	611		
		AI							- 	
		AJ								
		<u> </u>		Patent Applic	cation Publication	on				
			Publication Number	Pub. Date	Name		Class	Subclass	Filing Date If Appropriate	
4		AK	2002 0036001 A1	Маг. 28, 2002	Ise et al.		134	1.3		
LT		AL	2002 0053355 A1	May 9, 2002	Kamikawa et al.		134	30		
LT		AM	2003 0006513 A1	Jan. 9, 2003	Gotoh et al.		261	· 122.1		•
		AN								-
				Foreign Pat	ent Documents					
								Translation		
١			Document	Date	Country		Class	Subclass	Yes	No
		AO								
		AP								
	OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)									
	AQ									
	AR									
Exami	Examiner: Unauthan					Date Considered: 6 24 05				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.										